

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

November 14, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

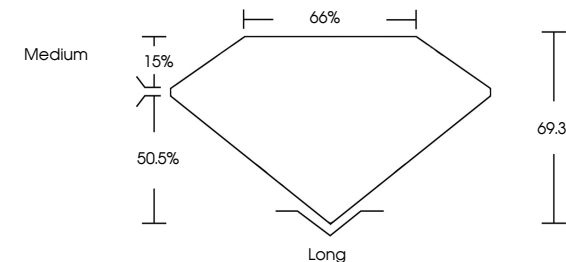
Inscription(s)


Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG749515042

Report verification at igi.org

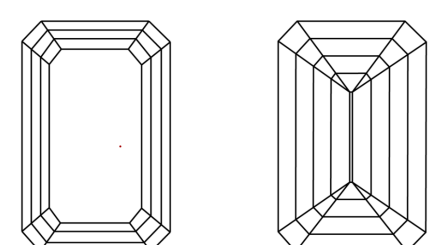
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR


D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

9.38 X 6.93 X 4.80 MM

3.05 CARATS

H


VVS 1

EXCELLENT

EXCELLENT

NONE

IGI LG749515042



IGI

November 14, 2025

IGI Report No LG749515042

EMERALD CUT

9.38 X 6.93 X 4.80 MM

3.05 CARATS

H

VVS 1

69.3%

50.5%

Medium

Long

EXCELLENT

EXCELLENT



NONE

IGI LG749515042

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

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